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(54) Title (EN): PRINT SUBSTRATE ALIGNMENT

(54) Title (FR): ALIGNEMENT DE SUBSTRAT D'IMPRESSION

(57) Abstract:

(EN): Lateral adjustment apparatus comprises a gripper to grip a print substrate, the gripper being mounted on a rotor rotatable about a lateral axis, and a lateral adjustment motor to drive movement of the gripper laterally along the rotor to adjust a lateral position of the print substrate. The lateral adjustment motor is mounted on the rotor.

(FR): L'invention concerne un appareil de réglage latéral comprenant un dispositif de préhension pour saisir un substrat d'impression, le dispositif de préhension étant monté sur un rotor pouvant tourner autour d'un axe latéral et un moteur de réglage latéral pour entraîner le mouvement du dispositif de préhension latéralement le long du rotor pour régler une position latérale du substrat d'impression. Le moteur de réglage latéral est monté sur le rotor.

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Declarations:

Declaration made as to the identity of the inventor (PCT Rules 4.17(i) and 51bis.1(a)(i))

Declaration made as applicant's entitlement, as at the international filing date, to apply for and be granted a patent (Rules 4.17(ii) and 51bis.1(a)(ii)), in a case where the declaration under Rule 4.17(iv) is not appropriate